



**BIHANI
GROUP**

About Chopanki, Bhiwadi

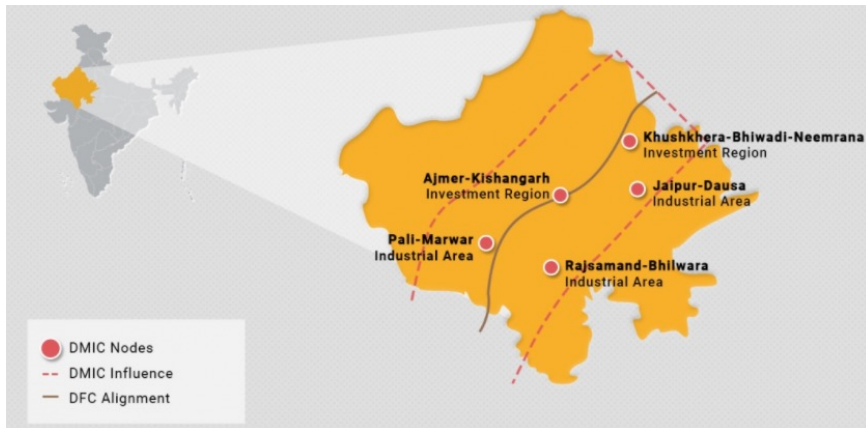
55 KMS FROM DELHI AIRPORT TOWARDS JAIPUR

ON INDIA'S MAIN HIGHWAY NH8

JAPANESE & KOREAN ZONES

AMONGST INDIA'S MOST RESPECTED INDUSTRIAL & INVESTMENT ZONES COVERS

- BHIWADI
- KHUSHKHERA
- NEEMRANA
- BAWAL

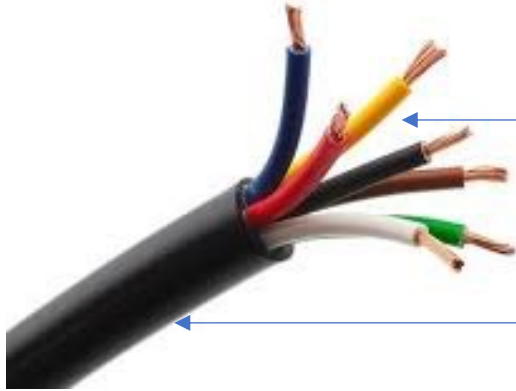




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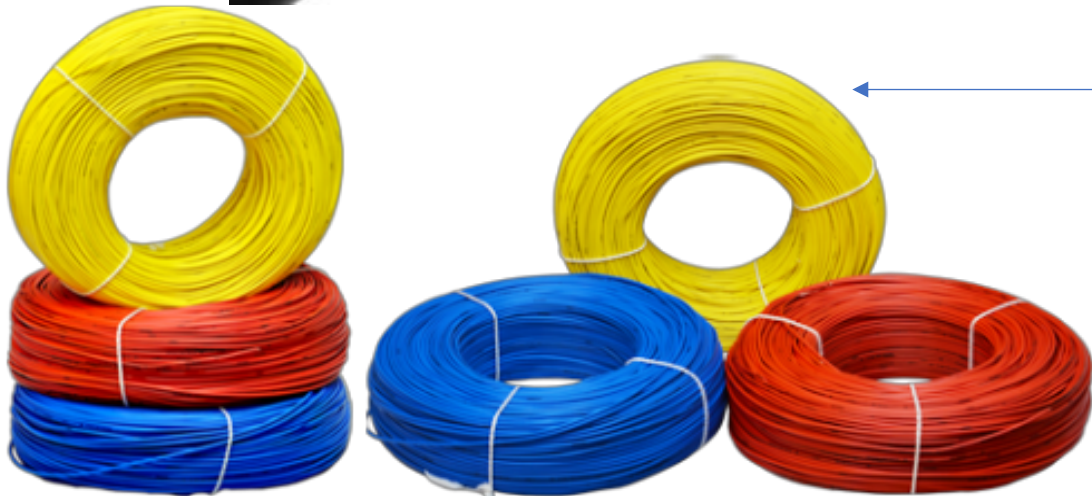


Grade	Application	Density
BM 28	Type A Insulation	1.50
BM 20	Type A Insulation	1.55
BM 116	Type A Insulation	1.56



Grade	Application	Density
F1	ST-1 Sheathing	1.50
F4	ST-1 Sheathing	1.53

Grade	Application	Density
BM20S	Gloss Sheathing	1.46
BM09	Gloss Sheathing	1.50



Grade	Application	Density
FR111	Type A FR Compound	1.50
FR110	Type A FR Compound	1.55
BM116FR	Type A FR Compound	1.58

Grade	Application	Density
BM23	Skin Compound with high gloss & slip	1.34
BM 21K	Skin Compound with high gloss & slip	1.32

Detailed Specs

Grade	Density (S)	T.S.	Elongation	Hardness	Thermal
	±0.03	N/mm ²	%	Shore A	Minutes
BM 20 (S)	1.46	15	250	87	120
BM 09	1.50	15	300	80	75
BM F1 (Black)	1.50	16	300	85	130
BM F4 L/F	1.53	15	250	85	135
BM 28	1.50	16	250	92	120
BM 20	1.55	16	250	92	120
BM 116	1.56	16	225	92	100
BM FR 111	1.50	17	250	93	125
BM FR 110	1.55	16	250	90	100
BM 116 FR	1.58	16	250	90	100
BM K-21	1.30	21	250	92	100
BM 23	1.32	20	250	95	100

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ISO 9001 : 2015 ♦ ISO 14001 :2004 ♦ ISO 22000 :2005 National Award 2006 ♦ National Award 2008